Accepted Manuscript

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PII: S0042-207X(15)00218-3

DOI: 10.1016/j.vacuum.2015.05.001

Reference: VAC 6660

To appear in: Vacuum

Received Date: 14 October 2014

Revised Date: 29 April 2015

Accepted Date: 1 May 2015

Please cite this article as: Yang TC-K, Yang Y-L, Juang R-C, Chiu T-W, Chen C-C, The novel preparation method of high-performance thermochromic vanadium dioxide thin films by thermal oxidation of vanadium-stainless steel co-sputtered films, *Vaccum* (2015), doi: 10.1016/j.vacuum.2015.05.001.

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ACCEPTED MANUSCRIPT

The novel preparation method of high-performance thermochromic vanadium dioxide thin films by thermal oxidation of vanadium-stainless steel co-sputtered films

Thomas C.-K. Yang*¹, Yue-Lin Yang¹, Rei-Chen Juang², Te-Wei Chiu³, Chien-Chung Chen⁴

¹Department of Chemical Engineering and Biotechnology,

National Taipei University of Technology, Taipei 106, Taiwan

²Green Energy and Environmental Laboratories,

Industrial Technology Research Institute, Hsinchu 300, Taiwan

³Department of Material and Mineral Resources Engineering,

National Taipei University of Technology, Taipei 106, Taiwan

⁴Graduate Institute of Biomedical Materials and Engineering,

Taipei Medical University, Taipei, Taiwan

*Corresponding author. Tel.: +886-2-2771-2171#2533; fax: +886-2-27760985.

E-mail address: ckyang@mail.ntut.edu.tw (Thomas C.-K. Yang)

Abstract

The preparation of high-performance thermochromic vanadium dioxide films and the assurance of its batch-to-batch uniformity is technically difficult since the oxidation number of vanadium ranges from +2 to +5 under various reducing or oxidizing atmospheres at elevated temperatures. In this work, the vanadium dioxide films were fabricated by thermal-oxidation of vanadium and stainless-steel (mainly containing Fe, Cr, Ni) co-sputtered thin films at elevated temperature under air atmosphere. The

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